ALTERED ITEM DRAWING

NOTES:
1. CLEANLINESS REQUIREMENTS PER SN-C-0005 LEVEL V0-SENSITIVE.
2. PERMANENT JMK STAMP PN AND REV LETTER IN 12 HIGH CHARACTERS WITH ITEM 1.
   LOCATION APPROXIMATELY WHERE SHOWN, ENGRAVING IS ACCEPTABLE.
3. ANODIZE PER NASA/JSC PRC 5006, CLASS 2 TYPE 11, COLOR BLACK.
4. MASK FROM BLACK ANODIZE AS SHOWN, CHEM FILM PER MIL-C-5541 CLASS 3.
5. MACHINE TO REMOVE STEM TO DIMENSION SHOWN.
   MACHINE TO REMOVE LIP TO DIMENSION SHOWN FROM TOP.

Massachusetts Institute of Technology
Center For Space Research
ASTRO-B2

UNLESS OTHERWISE SPECIFIED
DIMENSIONS ARE IN INCHES
TOLERANCE ANGLES +/- 1 °
3 PLACE DECADES +/- 0.001
2 PLACE DECIMALS +/- .001

MATERIAL

NOTE 4
FINISH

NAME: M. SMITH
DATE: 

DRAWN:  
CHECKED:  
APPROVED:  
REDRAWN:  

85-40705  

NOTE:  
ORDER:  

APPLICATION

SCALE: 1/1

DRAWN: XXXXX-V

REVISIONS

COMMERCIAL

REV. A
INITIAL RELEASE

COMMERCIAL